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11046 U.S. PTO  
09/991196

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Class	Subclass	ISSUE CLASSIFICATION

P

PATENT NUMBER

# U.S. UTILITY Patent Application

<p>SCANNED <i>TR2</i> <i>Q.A.</i></p>	<p>O.I.P.E.</p>	<p>PATENT DATE</p>
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APPLICATION NO. 09/991196	CONT/PRIOR D	CLASS 216	SUBCLASS 1	ART UNIT 1711	EXAMINER
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APPLICANTS  
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High density plasma chemical vapor deposition process

TITLE

PTO-2040  
12/99

## ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)						
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
INTERNATIONAL CLASSIFICATION								

☐ Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) _____ (Date)			<b>NOTICE OF ALLOWANCE MAILED</b>	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____	_____ (Primary Examiner) _____ (Date)			<b>ISSUE FEE</b>	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) _____ (Date)			Amount Due	Date Paid
			<b>ISSUE BATCH NUMBER</b>		

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